Author Index of Volume 217

Ahmad, A., 75
Aksenov, V. S., 102
Alterovitz, S. A., 156

Barnik, M. I., 167
Belikov, A. P., 102
Bercha, A. I., 62
Bernard, J., 178
Berry, A. R., 83
Black, D. R., 113
Blanpain, B., 56
Borman, V. D., 102
Breuer, K., 48
Buchal, Ch., 125

Cahoreau, M., 1
Chang, C., 68
Chopra, K. L., 146
Collins, R. A., 75
Croitoru, N., 193
Crousier, J. P., 31

Davydova, N. N., 167
Dekempeneer, E. H. A., 56
Denanot, M. F., 1
Dionisio, P. H., 152
Djouadi, M. A., 17
Draxler, S., 161

Eersels, L., 56
Ehrhardt, H., 48
Eymery, J. P., 1

Fan, G. H., 98
Fan, X. W., 98
Fang, Y., 174
Farabaugh, E. N., 113
Feldman, A., 113
Fuchs, A., 48

Gavrilenko, V. I., 62
Genut, M., 91
Gouault, J., 120
Gravier, P., 31
Guan, Z. P., 98
Guggi, D., 125

Hacker, E., 7
Hadj Moussa, S., 17
Hallouche, B., 152
Hamrin, Jr., C. E., 133
Heavens, O. S., 138
Hodes, G., 91

Jacobs, R., 56
Jia, C. L., 125
Jung, K., 48

Kaiser, N., 7
Kaiser, U., 7
Karamies, M. B., 38
Kashyap, S. C., 146
Ketipearachchi, U. S., 129
Khavrichev, V. A., 167
Khmelev, A. V., 102
Kim, J. S., 133
Kiridena, W. C. B., 129
Koller, E., 161
Konstantinov, K., 187
Korbutyak, D. V., 62
Korushonkov, Yu. G., 102
Kumar, S., 146

Laplanche, G., 1
le Bas, J., 120
Lechevallier, L., 120
Leong, J. Y., 68
Lippitsch, M. E., 161
Litovchenko, V. G., 62
Liu, L., 174
Liu, X., 174
Long, G. G., 113
Lu, X., 174
Lubig, A., 125

Mademann, U., 7
Mai, M., 108
Margulis, L., 91
Marinković, Ž., 26
Marzouk, H. A., 133
Massiani, Y., 31
McVittie, J. P., 68
Medjahed, A., 31
Meneve, J., 56
Merkel, U., 108
Milov, I. V., 102
Möbius, D., 178
Mosca, Jr., D. H., 152
Mühling, I., 48
Müller, H., 7

Nebauer, E., 108
Nordin, C. W., 83

Oostra, D. J., 56
Orrit, M., 178

Paito, S. P., 167
Pasa, A. A., 152
Pavelescu, C., 68
Personov, R. I., 178
Ploog, K., 62
Prokofyev, A. A., 102
Punchihewa, S., 129

Ratcheva, T., 187
Reucroft, P. J., 133
Richon, G., 120
Roos, J., 56

Sahli, S., 17
Saraswat, K. C., 68
Schreiner, W. H., 152
Segui, Y., 17
Seidman, A., 193
Senadeera, S., 129
Simić, V., 26
Smeets, J., 56
Song, S. H., 98
Spal, R. D., 113
Stambolova, I., 187
Stan, M. A., 156
Stritzker, B., 125

Talon, H., 178
Talysin, D. I., 102
Tanaka, D. K., 113
Teixeira, S. R., 152
Tennakone, K., 129
Tenne, R., 91

Vasquez, A., 152
Vitta, S., 156

Wang, W., 174
Warner, J. D., 156
Weißbrodt, P., 7

Yassin, K., 193
Yuan, Y. F., 138
Yudin, S. G., 167

Zhang, Z., 113
Zheng, J., 174

Subject Index of Volume 217

Alloys
  transport properties: conductivity, thermoelectric power and Hall constant on Au–Cr thin film alloys, obtained by controlled coevaporation, 120
Amorphous materials
  electrical transport in n-type bismuth modified a-$Ge_{20}Se_{80}$ and a-As_2Se_3 thin films, 146
  Some anomalous optical and electrical anomalous properties of $M/MoO_3/M$ sandwich structure, 138
Anisotropy
  photoinduced variations of the internal electric field in Langmuir–Blodgett films with azo dye monolayer, 167
Annealing
  ohmic behaviour of Au/WSiN/(AuGeNi)–n-GaAs systems, 108
Auger electron spectroscopy
  characterization of high quality *c* axis oriented ZnO thin films grown by MOCVD using zinc acetate as source material, 133
  structural and magnetic properties of iron–tin thin films, 152

Beryllium
  effect of silicon on the structure of beryllium films, 83
Bismuth
  electrical transport in n-type bismuth modified a-$Ge_{20}Se_{80}$ and a-As_2Se_3 thin films, 146

Carbon
  r.f. plasma-assisted chemical vapour deposition of diamond-like carbon: physical and mechanical properties, 56
Chemical vapour deposition
  high frequency $C-V$ investigation of metal–oxide–semiconductor capacitors prepared by low temperature subatmospheric pressure chemical vapour deposition of SiO_2 films on silicon substrates, 68
Chromium
  transport properties: conductivity, thermoelectric power and Hall constant of Au–Cr thin film alloys, obtained by controlled coevaporation, 120
Coatings
  r.f. plasma-assisted chemical vapour deposition of diamond-like carbon: physical and mechanical properties, 56
  effect of silicon on the structure of beryllium films, 83
Contacts
  ohmic behaviour of Au/WSiN/(AuGeNi)–n-GaAs systems, 108
Copper
  comparative analysis of interdiffusion in some thin film metal couples at room temperature, 26
Corrosion
  effect of a titanium underlayer on the corrosion behaviour of physically vapour deposited titanium nitride films, 31

Deposition process
  preparation and microstructure of WS_2 thin films, 91

Electrical properties
  high frequency $C-V$ investigation of metal–oxide–semiconductor capacitors prepared by low temperature subatmospheric pressure chemical vapour deposition of SiO_2 films on silicon substrates, 68
Electrical properties and measurements
  electrical transport in n-type bismuth modified a-$Ge_{20}Se_{80}$ and a-As_2Se_3 thin films, 146
  some anomalous optical and electrical anomalous properties of $M/MoO_3/M$ sandwich structure, 138
  effect of oxygen on the electrical characteristics of triclinic lead phthalocyanine, 75
  transport properties: conductivity, thermoelectric power and Hall constant of Au–Cr thin film alloys, obtained by controlled coevaporation, 120
Electrochemistry
  preparation of thin polycrystalline films of cuprous iodide and photoelectrochemical dye-sensitization, 129
Electron energy loss spectroscopy
  electron and ion radiation damage of a-C:H films detected by energy loss spectroscopy of reflected and transmitted electrons, 48
Electron microscopy
  preparation and microstructure of WS_2 thin films, 91
Epitaxy
  epitaxial growth of monoclinic and cubic ZrO_2 on Si(100) without prior removal of the native SiO_2, 125
  growth of high quality ZnSe epitaxial layers on transparent substrates CaF_2 by atmospheric pressure metallo-organic chemical vapour deposition, 98
Evaporation
  effect of silicon on the structure of beryllium films, 83

Fluourine
  r.f. megnetron deposition of calcium fluoride, 87
  structure of thin fluoride films deposited on amorphous substrates, 7

Gallium arsenide
  low-temperature photoluminescence of short-period GaAs/AlAs superlattices, 62
Gallium oxide
  ohmic behaviour of Au/WSiN/(AuGeNi)–n-GaAs systems, 108
Glow discharge
  growth, composition and structure of plasma-deposited siloxane and silazane, 17
  r.f. magnetron deposition of calcium fluoride, 87
  some effects of the plasma nitriding process on layer properties, 38
Gold
  comparative analysis of interdiffusion in some thin film metal couples at room temperature, 26
  transport properties: conductivity, thermoelectric power and Hall constant of Au–Cr thin film alloys, obtained by controlled coevaporation, 120
Growth mechanism
  growth, composition and structure of plasma-deposited siloxane and silazane, 17

Hardness
  some effects of the plasma nitriding process on layer properties, 38
Heterostructures
  growth of high quality ZnSe epitaxial layers on transparent substrates CaF_2 by atmospheric pressure metallo-organic chemical vapour deposition, 98

Inorganic compounds
preparation of thin polycrystalline films of cuprous iodide and photoelectrochemical dye-sensitization, 129
Interfaces
ohmic behaviour of Au/WSiN/(AuGeNi)–n-GaAs systems, 108
Ion bombardment
r.f. plasma-assisted chemical vapour deposition of diamond-like carbon: physical and mechanical properties, 56

Langmuir–Blodgett films
enhancement of the second-order hyperpolarizability of a stilbene dye by molecular interactions, 161
photoinduced variations of the internal electric field in Langmuir–Blodgett films with azo dye monolayer, 167
Stark effect in hole-burning spectra of dye-doped Langmuir–Blodgett films, 178
Luminescense
low-temperature photoluminescence of short-period GaAs/AlAs superlattices, 62

Magnetic properties
magnetic flux relaxation in $YBa_2Cu_3O_{7-x}$ thin film: thermal or athermal, 156
structural and magnetic properties of iron–tin thin films, 152
structural investigation of b.c.c. 304 stainless steel, 1
Metal–organic chemical vapour
characterization of high quality *c* axis oriented ZnO thin films grown by MOCVD using zinc acetate as source material, 133
Metal–oxide semiconductor structures
high frequency $C-V$ investigation of metal–oxide–semiconductor capacitors prepared by low temperature subatmospheric pressure chemical vapour deposition of SiO_2 films on silicon substrates, 68
Molybdenum oxide
some anomalous optical and electrical anomalous properties of $M/MoO_3/M$ sandwich structure, 138
Monolayers
Stark effect in hole-burning spectra of dye-doped Langmuir–Blodgett films, 189
Mössbauer spectroscopy
structural investigation of b.c.c. 304 stainless steel, 1
Multilayers
effect of a titanium underlayer on the corrosion behaviour of physically vapour deposited titanium nitride films, 31
preparation of thin polycrystalline films of cuprous iodide and photoelectrochemical dye-sensitization, 129
Stark effect in hole-burning spectra of dye-doped Langmuir–Blodgett films, 178

Optical coatings
enhancement of the second-order hyperpolarizability of a stilbene dye by molecular interactions, 161
structure of thin fluoride films deposited on amorphous substrates, 7
Optical properties
alterations in optical properties of materials covered with oxide films during laser heating in gases, 102
electrical transport in n-type bismuth modified $a\text{-}Ge_{20}Se_{80}$ and $a\text{-}As_2Se_3$ thin films, 146
growth of high quality ZnSe epitaxial layers on transparent substrates CaF_2 by atmospheric pressure metallo-organic chemical vapour deposition, 98
low temperature photoluminescence of short-period GaAs/AlAs superlattices, 62
photoinduced variations of the internal electric field in Langmuir–Blodgett films with azo dye monolayer, 167
some anomalous optical and electrical anomalous properties of $M/MoO_3/M$ sandwich structure, 138
Optical spectroscopy
Stark effect in hole-burning spectra of dye-doped Langmuir–Blodgett films, 178
Organic substances
effect of oxygen on the electrical characteristics of triclinic lead phthalocyanine, 75
Oxides
epitaxial growth of monoclinic and cubic ZrO_2 on Si(100) without prior removal of the native SiO_2, 125
structure of vapor-deposited yttria and zirconia thin films, 113
theoretical expressions for secondary electron emission from metal oxide films as a function of measurable variables, 193
Oxygen
effect of oxygen on the electrical characteristics of triclinic lead phthalocyanine, 75

Photovoltage
preparation of thin polycrystalline films of cuprous iodide and photoelectrochemical dye-sensitization, 129
Physical vapour deposition
effect of a titanium underlayer on the corrosion behaviour of physically vapour deposited titanium nitride films, 31
structure of thin fluoride films deposited on amorphous substrates, 7
Plasma processing
some effects of the plasma nitriding process on layer properties, 38
Plasma processing and deposition
growth, composition and structure of plasma-deposited siloxane and silazane, 17
r.f. plasma-assisted chemical vapour deposition of diamond-like carbon: physical and mechanical properties, 56
Polymers
growth, composition and structure of plasma-deposited siloxane and silazane, 17
Pyrolysis
copper-doped SnO_2 thin films for PH_3 detection, 187

Quantum effects
magnetic flux relaxation in $YBa_2Cu_3O_{7-x}$ thin film: thermal or athermal, 156

Rutherford backscattering
epitaxial growth of monoclinic and cubic ZrO_2 on Si(100) without prior removal of the native SiO_2, 125
structural and magnetic properties of iron–tin thin films, 152

Second harmonic generation
enhancement of the second-order hyperpolarizability of a stilbene dye by molecular interactions, 161
Secondary electron emission
theoretical expressions for secondary electron emission from metal oxide films as a function of measurable variables, 193
Semiconductors
effect of oxygen on the electrical characteristics of triclinic lead phthalocyanine, 75
Sensors
copper-doped SnO_2 thin films for PH_3 detection, 187

Silicon oxide
high frequency $C-V$ investigation of metal–oxide–semiconductor capacitors prepared by low temperature subatmospheric pressure chemical vapour deposition of SiO_2 films on silicon substrates, 68
Sputtering
r.f. magnetron deposition of calcium fluoride, 87
Steels
structural investigation of b.c.c. 304 stainless steel, 1
Stress
growth of high quality ZnSe epitaxial layers on transparent substrates CaF_2 by atmospheric pressure metallo-organic chemical vapour deposition, 98
Structural properties
enhancement of the second-order hyperpolarizability of a stilbene dye by molecular interactions, 161
structural and magnetic properties of iron–tin thin films, 152
structural investigation of b.c.c. 304 stainless steel, 1
structure of thin fluoride films deposited on amorphous substrates, 7
Sulphides
preparation and microstructure of WS_2 thin films, 91
Superconductivity
magnetic flux relaxation in $YBa_2Cu_3O_{7-x}$ thin film: thermal or athermal, 156
Superlattices
low-temperature photoluminescence of short-period GaAs/AlAs superlattices, 62
Surface diffusion
some effects of the plasma nitriding process on layer properties, 38

Tin oxide
copper-doped SnO_2 thin films for PH_3 detection, 187
Titanium nitride
effect of a titanium underlayer on the corrosion behaviour of physically vapour deposited titanium nitride films, 31
Transmission electron spectros
electron and ion radiation damage of a-C:H films detected by energy loss spectroscopy of reflected and transmitted electrons, 48
Tungsten
preparation and microstructure of WS_2 thin films, 91

X-ray adsorption
structure of vapor-deposited yttria and zirconia thin films, 113
X-ray diffraction
characterization of high quality c axis oriented ZnO thin films grown by MOCVD using zinc acetate as source material, 133
X-ray photoelectron spectroscopy
characterization of high quality c axis oriented ZnO thin films grown by MOCVD using zinc acetate as source material, 133
r.f. magnetron deposition of calcium fluoride, 87

Yttrium
structure of vapor-deposited yttria and zirconia thin films, 113

Zirconium
epitaxial growth of monoclinic and cubic ZrO_2 on Si(100) without prior removal of the native SiO_2, 125
structure of vapor-deposited yttria and zirconia thin films, 113